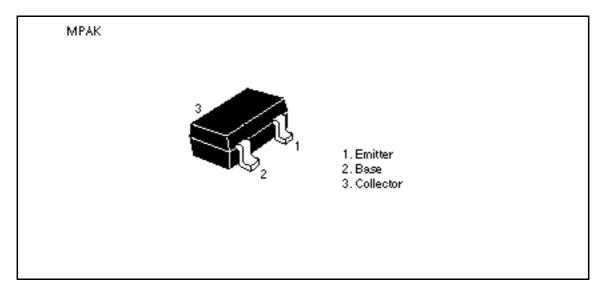
Silicon NPN Epitaxial



Application

Low frequency amplifier, Muting

Outline





Absolute Maximum Ratings (Ta = 25° C)

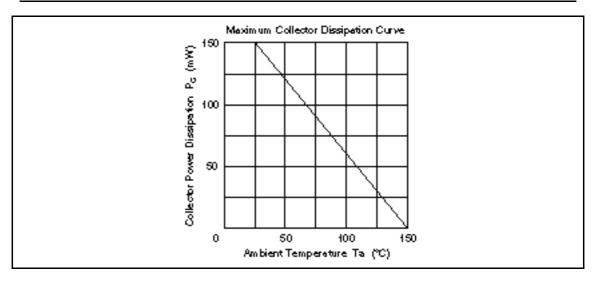
Item	Symbol	Ratings	Unit
Collector to base voltage	V _{CBO}	30	V
Collector to emitter voltage	V _{CEO}	15	V
Emitter to base voltage	V _{EBO}	5	V
Collector current	I _c	0.7	А
Collector power dissipation	Pc	150	mW
Junction temperature	Tj	150	°C
Storage temperature	Tstg	-55 to +150	°C

Electrical Characteristics (Ta = 25° C)

Item		Symbol	Min	Тур	Мах	Unit	Test conditions	
Collector t voltage	o base breakdown	$V_{(BR)CBO}$	30	_	_	V	$I_{c} = 10 \ \mu A, \ I_{E} = 0$	
Collector t voltage	o emitter breakdow	n V _{(BR)CEO}	15	_	_	V	$I_c = 1 \text{ mA}, R_{BE} =$	
Emitter to voltage	base breakdown	$V_{(BR)EBO}$	5	_	—	V	$I_{\rm E} = 10 \ \mu A, \ I_{\rm C} = 0$	
Collector of	cutoff current	I _{CBO}	_		1.0	μA	$V_{CB} = 20 \text{ V}, \text{ I}_{E} = 0$	
DC curren	t transfer ratio	h_{FE}^{*1}	250		800		V_{ce} = 1 V, I_c = 150 mA ^{*2}	
Base to er	nitter voltage	V _{BE}			1.0	V	V_{ce} = 1 V, I _c = 150 mA ^{*2}	
Collector t voltage	o emitter saturatior	V _{CE(sat)}	—	_	0.5	V	$I_{c} = 500 \text{ mA}, I_{B} = 50 \text{ mA}^{*2}$	
Gain band	lwidth product	f _⊤	_	250	_	MHz	V_{ce} = 1 V, I_c = 150 mA ^{*2}	
Notes: 1. The 2SD1306 is grouped by h_{FE} as follows.								
2.	Pulse test							
Grade	D	E						
Mark	ND	NE	-					

h_{FE} 250 to 500 400 to 800

See characteristic curves of 2SD1504.



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